

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application of:	Toshihiko OHASHI et al.		
Application No.:	10/541,776	Confirmation No.:	1474
Filed:	July 08, 2005	Art Unit:	1794
For:	SILICA-CONTAINING LAMINATED STRUCTURE, AND COATING COMPOSITION FOR USE IN FORMING A POROUS SILICA LAYER	Examiner:	V. CHANG

REPLY UNDER 37 C.F.R. § 1.114

MS AF
Commissioner for Patents
P.O. Box 1450
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Sir:

INTRODUCTORY COMMENTS

In reply to the Office Action dated December 17, 2009, the following amendments and remarks are respectfully submitted with a Request for Continued Examination (RCE) in connection with the above-identified application.

Remarks begin on page 2.